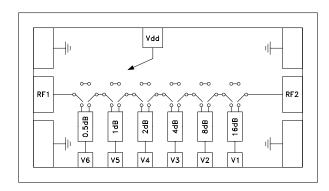


Typical Applications

The HMC425 is ideal for:

- Fiber Optics & Broadband Telecom
- Microwave Radio & VSAT
- Military Radios, Radar, & ECM
- Space Applications

Functional Diagram



Features

0.5 dB LSB Steps to 31.5 dB
Single Control Line Per Bit
+/- 0.5 dB Typical Bit Error

Die Size: 0.85 mm x 1.5 mm x 0.1 mm

General Description

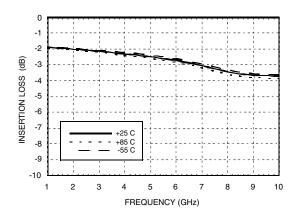
The HMC425 die is a broadband 6-bit GaAs IC digital attenuator MMIC chip. Covering 2.4 to 8.0 GHz, the insertion loss is less then 3.5 dB typical. The attenuator bit values are 0.5 (LSB), 1, 2, 4, 8, and 16 dB for a total attenuation of 31.5 dB. Attenuation accuracy is excellent at \pm 0.5 dB typical step error with an IIP3 of +40 dBm. Six control voltage inputs, toggled between 0 and +3 to +5V, are used to select each attenuation state. A single Vdd bias of +3 to +5V is required.

Electrical Specifications, $T_A = +25^{\circ} C$, With Vdd = +5V & Vctl = 0/+5V (Unless Otherwise Noted)

Parameter		Frequency (GHz)	Min.	Тур.	Max.	Units
Insertion Loss		2.4 - 6.0 GHz 6.0 - 8.0 GHz		2.7 3.5	3.2 4.0	dB dB
Attenuation Range	2.4 - 8.0 GHz		31.5		dB	
Return Loss (RF1 & RF2, All Atten. States)	2.4 - 8.0 GHz	12	15		dB	
Attenuation Accuracy: (Referenced to Insertion Loss)	All States	2.4 - 8.0 GHz	± 0.4 + 4% of Atten. Setting Max		dB	
Input Power for 0.1 dB Compression	Vdd= 5V Vdd= 3V	2.4 - 8.0 GHz		22 19		dBm dBm
The state of the s	REF - 16.0 dB States 16.5 - 31.5 dB States	2.4 - 8.0 GHz		45 35		dBm dBm
Switching Characteristics		2.4 - 8.0 GHz				
tRISE, tFALL (10/90% RF) tON/tOFF (50% CTL to 10/90% RF)				160 180		ns ns

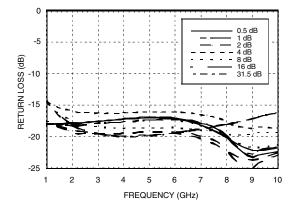


Insertion Loss



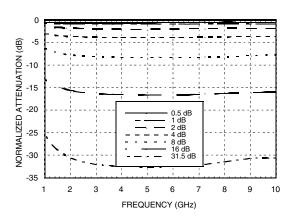
Return Loss RF1, RF2

(Only Major States are Shown)

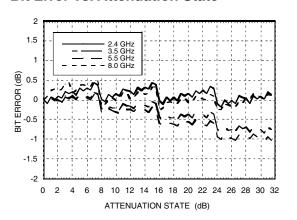


Normalized Attenuation

(Only Major States are Shown)

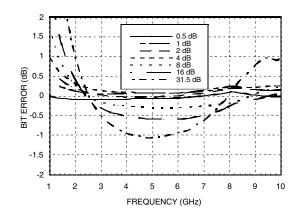


Bit Error vs. Attenuation State



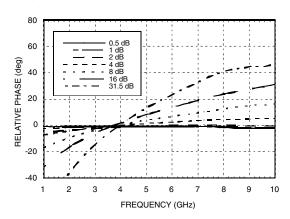
Bit Error vs. Frequency

(Only Major States are Shown)



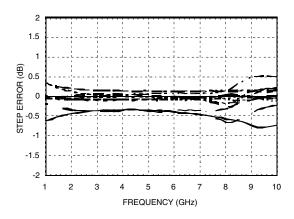
Relative Phase vs. Frequency

(Only Major States are Shown)





Worst Case Step Error Between Successive Attenuation States



Truth Table

	Control Voltage Input					Attenuation	
V1 16 dB	V2 8 dB	V3 4 dB	V4 2 dB	V5 1 dB	V6 0.5 dB	State RF1 - RF2	
High	High	High	High	High	High	Reference I.L.	
High	High	High	High	High	Low	0.5 dB	
High	High	High	High	Low	High	1 dB	
High	High	High	Low	High	High	2 dB	
High	High	Low	High	High	High	4 dB	
High	Low	High	High	High	High	8 dB	
Low	High	High	High	High	High	16 dB	
Low	Low	Low	Low	Low	Low	31.5 dB	

Any Combination of the above states will provide an attenuation approximately equal to the sum of the bits selected.

Bias Voltage & Current

Vdd Range= +3.0 to +5.0 Vdc				
Vdd (Vdc)	ldd (Typ.) (µA)			
+3.0	10			
+5.0	30			

Control Voltage

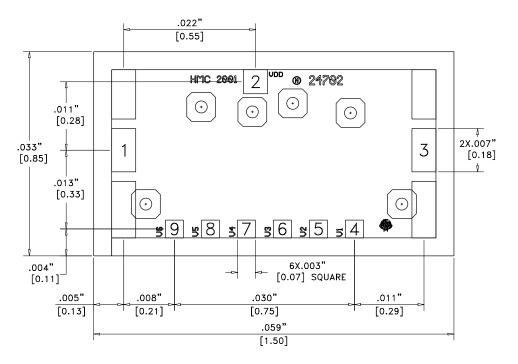
State	Bias Condition	
Low	0 to 0.2V @ 10 μA Typ.	
High	Vdd ± 0.2V @ 5 μA Typ.	
Note: Vdd= +3V to +5V		

Absolute Maximum Ratings

Control Voltage (V1 to V6)	Vdd +0.5 Vdc
Bias Voltage (Vdd)	+7.0 Vdc
Storage Temperature	-65 to + 150 °C
Operating Temperature	-55 to +85 °C
RF Input Power (2.4 - 8.0 GHz)	+30 dBm



Outline Drawing



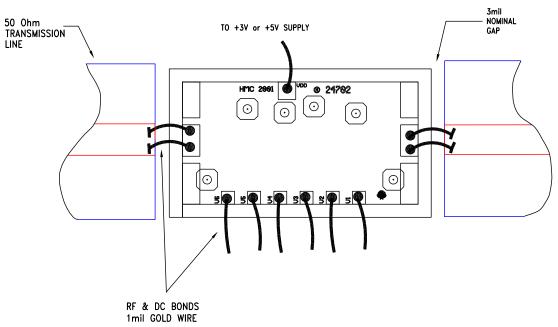
- 1. ALL DIMENSIONS ARE IN INCHES (MILLIMETERS).
- 2. TYPICAL BOND PAD IS .004" SQUARE.
- 3. TYPICAL BOND PAD SPACING IS .006" CENTER TO CENTER EXCEPT AS NOTED.
- 4. BACKSIDE METALIZATION: GOLD
- 5. BACKSIDE METAL IS GROUND
- 6. BOND PAD METALIZATION: GOLD

Pad Descriptions

Pad Number	Function	Description	Interface Schematic	
	GND	Die bottom must be connected to RF ground.		
1, 3	RF1, RF2	This pad is DC coupled and matched to 50 Ohm. Blocking capacitors are required.		
2	Vdd	Supply Voltage		
4, 5, 6, 7, 8, 9	V1 - V6	See truth table and control voltage table.	500 ———————————————————————————————————	



Assembly Diagram

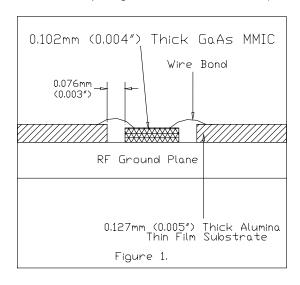


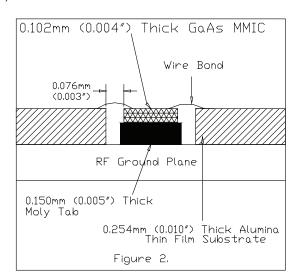
Mounting & Bonding Techniques for Millimeterwave GaAs MMICs

The die should be attached directly to the ground plane eutectically or with conductive epoxy (see HMC general Handling, Mounting, Bonding Note).

50 Ohm Microstrip transmission lines on 0.127mm (5 mil) thick alumina thin film substrates are recommended for bringing RF to and from the chip (Figure 1). If 0.254mm (10 mil) thick alumina thin film substrates must be used, the die should be raised 0.150mm (6 mils) so that the surface of the die is coplanar with the surface of the substrate. One way to accomplish this is to attach the 0.102mm (4 mil) thick die to a 0.150mm (6 mil) thick molybdenum heat spreader (moly-tab) which is then attached to the ground plane (Figure 2).

Microstrip substrates should be brought as close to the die as possible in order to minimize bond wire length. Typical die-to-substrate spacing is 0.076mm to 0.152 mm (3 to 6 mils).







Handling Precautions

Follow these precautions to avoid permanent damage.

Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.

Static Sensitivity:

Follow ESD precautions to protect against $> \pm 250$ V ESD strikes.

Transients:

Suppress instrument and bias supply transients while bias is applied. Use shielded signal and bias cables to minimize inductive pick-up.

General Handling:

Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers. The surface of the chip has fragile air bridges and should not be touched with vacuum collet, tweezers, or fingers.

Mounting

The chip is back-metallized and can be die mounted with AuSn eutectic preforms or with electrically conductive epoxy. The mounting surface should be clean and flat.

Eutectic Die Attach:

A 80/20 gold tin preform is recommended with a work surface temperature of 255 deg. C and a tool temperature of 265 deg. C. When hot 90/10 nitrogen/hydrogen gas is applied, tool tip temperature should be 290 deg. C. DO NOT expose the chip to a temperature greater than 320 deg. C for more than 20 seconds. No more than 3 seconds of scrubbing should be required for attachment.

Epoxy Die Attach:

Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip once it is placed into position. Cure epoxy per the manufacturer's schedule.

Wire Bonding

Ball or wedge bond with 0.025 mm (1 mil) diameter pure gold wire. Thermosonic wirebonding with a nominal stage temperature of 150 deg. C and a ball bonding force of 40 to 50 grams or wedge bonding force of 18 to 22 grams is recommended. Use the minimum level of ultrasonic energy to achieve reliable wirebonds. Wirebonds should be started on the chip and terminated on the package or substrate. All bonds should be as short as possible <0.31 mm (12 mils).